

Search Notes

Application No.

10/025,144

Examiner

Stephen W. Smoot

Applicant(s)

MOON ET AL.

Art Unit

2813

SEARCHED

Class	Subclass	Date	Examiner
438	626	4/27/2004	SWS
438	633	4/27/2004	SWS
438	687	4/27/2004	SWS
438	690	4/27/2004	SWS
438	691	4/27/2004	SWS
438	692	4/27/2004	SWS
451	41	4/27/2004	SWS

INTERFERENCE SEARCHED

Class	Subclass	Date	Examiner
Same as Above		4/27/2004	SWS

**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

	DATE	EXMR
Key Words: CMP - Copper, Barrier Layer, Tantalum;	4/27/2004	SWS
Linear Velocity; Carrier Head; Membrane; Retaining Ring; Polishing Pad; Platen;	4/27/2004	SWS
Pressure (psi); Rotation (rpm); Accelerate (rpm per second).	4/27/2004	SWS
Search tools - EAST (attached): USPAT; US PG PUBS; Derwent; EPO; JPO; IBM TDB	4/27/2004	SWS